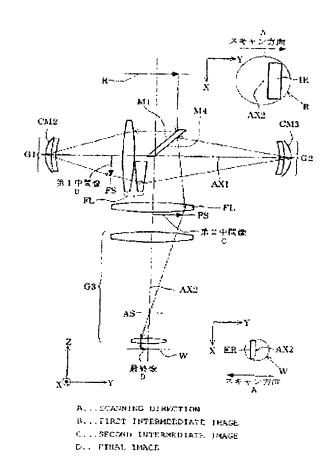
## CATADIOPTRIC SYSTEM AND EXPOSURE SYSTEM PROVIDED WITH THE SYSTEM

Patent number: WO02103431 Also published as: **Publication date:** 2002-12-27 JP2002372668 (A) Inventor: TAKAHASHI TOMOWAKI (JP) Applicant: NIPPON KOGAKU KK (JP); TAKAHASHI TOMOWAKI Cited documents: (JP) Classification: JP8021955 - international: G02B17/08; H01L21/027 JP7072393 JP7013070 - european: G02B17/08; G03F7/20T16 JP6242379 Application number: WO2002JP05259 20020530 JP8062502

## Abstract of WO02103431

A catadioptric system comprising a first image forming optical system (G1) having a concave reflection mirror (CM2) and a plane reflection mirror &lpar,M1) and used to form the first intermediate image of a first plane (R) based on light from the first plane, a second image forming optical system (G2) having a concave reflection mirror ( CM3) and a plane reflection mirror (M4) and used to form the second intermediate image of the first plane based on light via the first image forming optical system, and a third refractive type image forming optical system (G3) for forming the final image of the first plane on a second plane ( W) based on light via the second image forming optical system&period:

Priority number(s): JP20010179579 20010614



more >>

Data supplied from the esp@cenet database - Worldwide